

Customer No.: 31561  
Application No.: 10/710,785  
Docket No.: 12432-US-PA

**AMENDMENT**

**To the Claims:**

Claim 1 (original) A method for fabricating a thin film of an organic electroluminescent device, adapted to form a patterned thin film layer on a substrate, the method comprising:

providing a mask;

aligning the substrate and the mask under non-vacuum environment, fastening the mask with the substrate; and

transferring the fastened substrate and mask into vacuum environment, forming the patterned thin film layer by the mask.

Claim 2 (withdrawn) The method for fabricating a thin film of an organic electroluminescent device of claim 1, wherein the non-vacuum environment is atmosphere environment.

Claim 3 (original) The method for fabricating a thin film of an organic electroluminescent device claim 1, wherein the non-vacuum environment is environment having water and/or oxygen concentration about from 0.1 to 100 ppm.

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Claim 4 (original) The method for fabricating a thin film of an organic electroluminescent device of claim 1, wherein the patterned thin film layer is formed by vapor deposition or sputtering.

Claim 5 (currently amended) The method for fabricating a thin film of an organic electroluminescent device of claim 1, wherein the step of forming the patterned thin film layer comprises:

forming a first conductive layer on the substrate by using the mask; and  
forming a second conductive layer on the first conductive layer by using the mask.

Claim 6 (original) A method for fabricating a thin film of an organic electroluminescent device, adapted to form a patterned thin film layer on a substrate, the method comprising:

providing a film-forming apparatus, comprising at least one vacuum chamber and at least one non-vacuum chamber;

aligning the substrate and the mask in the non-vacuum chamber, fastening the mask with the substrate; and

transferring the fastened substrate and mask into the vacuum chamber, forming the patterned thin film layer by the mask.

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Claim 7 (withdrawn) The method for fabricating a thin film of an organic electroluminescent device of claim 6, wherein the non-vacuum environment is atmosphere environment.

Claim 8 (original) The method for fabricating a thin film of an organic electroluminescent device of claim 6, wherein the non-vacuum environment is environment having water and/or oxygen concentration about from 0.1 to 100 ppm.

Claim 9 (original) The method for fabricating a thin film of an organic electroluminescent device of claim 6, wherein the patterned thin film layer is formed by vapor deposition or sputtering.

Claim 10 (original) The method for fabricating a thin film of an organic electroluminescent device of claim 6, wherein the step of forming the patterned thin film layer comprises:

forming a first conductive layer on the substrate by using the mask; and  
forming a second conductive on the first conductive layer by using the mask.

Claims 11-32 (Canceled)